

1026 - (12-13, 16-17)

[First Hit](#)[Previous Doc](#)[Next Doc](#)[Go to Doc#](#)

Generate Collection

Print

L1: Entry 6 of 10

File: DWPI

Jun 15, 1994

DERWENT-ACC-NO: 1995-080487

DERWENT-WEEK: 199511

COPYRIGHT 2005 DERWENT INFORMATION LTD

Tsepochkina

TITLE: Etching soln. for prodn. of matt surface on silicate materials and glass -  
contains hydrofluoric acid, sulphuric acid, glycerine, acetone@ and ethylene glycol

INVENTOR: TSEPOCHKINA YU, A

PRIORITY-DATA: 1992SU-5024817 (January 9, 1992)

Search Selected

Search ALL

Clear

## PATENT-FAMILY:

PUB-NO	PUB-DATE	LANGUAGE	PAGES	MAIN-IPC
<input type="checkbox"/> RU 2014302 C1	June 15, 1994		002	C03C015/00

INT-CL (IPC): C03C 15/00

ABSTRACTED-PUB-NO: RU 2014302C

## BASIC-ABSTRACT:

The soln. contains (in wt.%): HF 21-22; H2SO4 51.5-53.0; glycerine 10-11.5; acetone 3.5-4.0; and ethylene glycol 11.5-12.0.

USE - Forms matt surfaces on silicate materials and glasses.

ADVANTAGE - Uniformity of treatment is improved.

[Previous Doc](#)[Next Doc](#)[Go to Doc#](#)